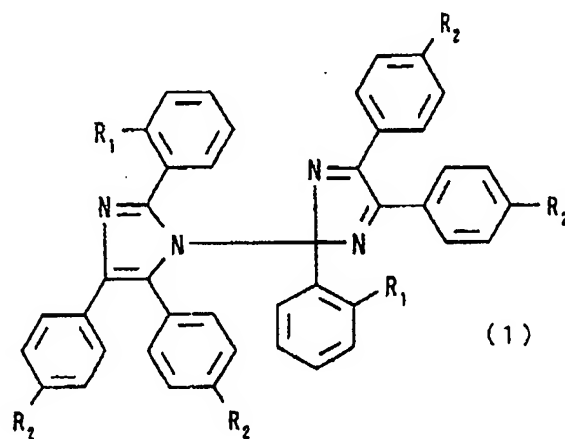


AMENDMENTS TO THE SPECIFICATION

Please replace the present Abstract of the Disclosure with the following amended Abstract of the Disclosure (a copy of the amended Abstract which can be substituted into the application is attached):

The present invention provides a novel hexaarylbiimidazole compound of the following formula (1):



wherein each R₁ represents a halogen, and each R₂ represents an optionally substituted C₁₋₄ alkyl group. The hexaarylbiimidazole compound of the present invention is useful as a photoradical generator in photopolymerizable compositions used as resists and is characterized by low sublimating thermal decomposition products. The photopolymerizable compositions may be suitably used as resists or as color filters for color liquid crystal display elements, cameras and the like.

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